

PAPER

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Hierarchical nanostructures of nitrogen-doped molybdenum sulphide for supercapacitors†

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Flower-like nanostructures of molybdenum disulphide (MoS_2) have been effectively synthesised by the hydrothermal method and further doped with nitrogen using varying concentrations of urea. The formed hierarchical nanostructures are characterised by spectroscopy as well as electrochemical techniques. The structural analysis confirms the formation of a hexagonal MoS_2 crystal structure. The existence of $\text{MoO}_2/\text{MoO}_3/\text{MoS}_2$ composites is also observed after heating MoS_2 with a lower urea concentration. Surface morphological analysis of all the prepared compositions shows the appearance of flower-like nanostructures formed by the stacking of 20–80 nanosheets to create individual flower petals. Nitrogen doping shows enhancement in the specific capacitance of MoS_2 due to an increase in the electronic conductivity. Furthermore, the specific capacitance is enhanced due to the formation of an $\text{MoO}_2/\text{MoO}_3/\text{MoS}_2$ composite. The highest specific capacitance calculated from the charge–discharge curve for nitrogen-doped MoS_2 prepared using 1 : 1 (MoS_2 : urea) weight ratio is observed at around 129 (F g^{-1}) at 2 (A g^{-1}) specific current. The nitrogen-doped MoS_2 demonstrates almost four-fold enhancement in specific capacitance than pristine nano-shaped MoS_2 .

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Introduction

Supercapacitors are efficient energy storage devices that act as a link between traditional capacitors and batteries. Higher power densities, longer life cycles and fast charging-discharging rates of supercapacitors play important roles in applications in industrial energy management, military devices, transportation, portable devices, memory and power backups, and hybrid vehicles.^{1–4} These high-energy capacitors have importance in scientific research as clean energy sources.

There are two different types of charge storage mechanisms for supercapacitors; the first one is double-layer capacitance that arises due to non-faradaic charge separation at the electrolyte/electrode interface, and the second one is pseudocapacitance that arises due to a surface redox reaction of the active materials such as conducting polymers, metal oxides and

hydroxides. Carbon materials such as active carbon, carbon nanotubes, and graphene are the most commonly used electrode materials owing to their high surface area and electrical conductivity, and they come under the category of double layer capacitors.^{1,5–7} Metal organic frameworks, metal oxides, and metal sulphides/selenides have also been reported as supercapacitor electrodes because of the presence of pseudocapacitance.^{8–17} The common strategy to enhance the capacitance of supercapacitors is to form composites using metal oxides and conducting polymers with carbon materials to obtain pseudocapacitance as well as double-layer capacitance.

Molybdenum disulphide (MoS_2) is a two-dimensional transition metal dichalcogenide that has a layered sheet-like structure. MoS_2 acts as a good electrode material due to the presence of both pseudocapacitance and double-layer capacitance. The large surface area of layered MoS_2 is responsible for double-layer capacitance, whereas redox reactions at the Mo metal center give rise to pseudocapacitance. Therefore, MoS_2 can replace composites of metal oxides and carbon as it has faster intrinsic ionic conductivity than oxides and higher theoretical capacitance than graphite ($\sim 700 \text{ F cm}^{-3}$).¹⁸ There are only few investigations on MoS_2 as an electrode material for electrochemical applications.^{10,19,20} Some of the reports include doping and composite formation of MoS_2 with graphene/nitrogen-doped graphene for supercapacitor and battery applications.^{21–26}

The main difficulty in using MoS_2 electrode in supercapacitor applications is its low rate performance and capacity fading.²⁵ The use of nanomaterials and doped materials can

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enhance the electrochemical performance of MoS₂ and help overcome these capacitance problems. There are reports demonstrating enhancement in the electronic properties of MoS₂ by doping with transition metals.^{27,28} Nevertheless, non-metal doping of MoS₂ that increases supercapacitor performance has not yet been reported. Nitrogen-doped graphene has shown enhanced performance for supercapacitors and other energy storage devices.^{29–33} In the case of graphene, defects improve the storage capacity of the graphene electrode but decrease its conductivity; therefore, the overall performance of the graphene electrode decreases. Nitrogen doping helps to improve this decreased performance by enhancing the conductivity.^{30–32} MoS₂ nanosheets are similar to graphene sheets; therefore, nitrogen-doped MoS₂ can be expected to show enhanced performance as an electrode material for supercapacitors.

In this regard, for the first time, we report the synthesis of MoS₂ and nitrogen-doped MoS₂ nanosheets as electrode materials for supercapacitor applications using a hydrothermal route. The increase in nitrogen doping in MoS₂ shows marginal increase in specific capacitance due to enhancement in electronic conductivity.

Experimental

Chemicals

Ammonium heptamolybdate tetrahydrate, thiourea, urea, and sulphuric acid were purchased from Sigma Aldrich and used as such without further purification.

Synthesis of 2H-MoS₂

The hydrothermal method was used to synthesize semi-conducting hexagonal molybdenum disulphide nanostructures. In a typical experimental procedure, ammonium heptamolybdenate and thiourea were used as molybdenum and sulphur precursors, respectively, to synthesize MoS₂. A mixture of ammonium heptamolybdenate and thiourea in 60 ml of water was prepared by keeping the molar ratio of Mo : S as 1 : 8. Then, this mixture was transferred to a Teflon-lined stainless steel autoclave. The sealed autoclave was kept at 200 °C for 24 h in a hot air oven. The obtained reaction product was washed with water and subsequently with ethanol. This powder was dried in a vacuum oven at 50 °C for 5 h and used for further process.

Nitrogen doping of MoS₂

The synthesised 2H-MoS₂ powder was heated in a tube furnace under a nitrogen environment at 400 °C for 4 h. The obtained product was termed as MoS₂-400. Furthermore, to dope with nitrogen, MoS₂-400 was mixed with urea in weight ratios of 1 : 1 and 1 : 5 and subsequently heated in a tube furnace at 400 °C for 30 min under a nitrogen environment; the obtained products were termed as MoS₂-N1 and MoS₂-N5, respectively.

Characterisation

As-synthesized MoS₂, MoS₂-400, MoS₂-N1 and MoS₂-N5 nanostructures were characterized by different spectroscopic

techniques. The phase purity of the materials was determined by X-ray diffraction (XRD) using a Bruker AXS D8 Advance powder X-ray diffractometer with Cu K α radiation ($\lambda = 1.5417$ Å). The diffraction patterns were recorded in the range of 2θ (10° to 80°) with a step size of 0.01°. Raman spectra were recorded using Jobin Yvon HORIBA LabRAM HR visible micro Raman system, employing a He–Ne laser operating at 632.8 nm as the source in the backscattering mode. The morphology of the materials was studied by scanning electron microscopy with a ZeissTM Ultra Plus field-emission scanning electron microscope (FESEM) equipped with an energy-dispersive X-ray (EDAX) spectrometer. Field emission transmission electron microscopy (FETEM, JEOL, JEM-2200FS) operated at 200 keV was used to obtain the morphology and SAED pattern for synthesised MoS₂ nanomaterials. X-ray photoelectron spectroscopy (XPS) of the prepared MoS₂ materials was performed with MultiLab 2000, Thermo VG with Mg K α X-ray source to determine the chemical compositions of the samples.

Electrochemical measurements were carried out using three-electrode cell configuration on Autolab PGSTAT302N. Cyclic voltammetry measurements of the MoS₂ electrodes were performed in H₂SO₄ electrolyte at different scan rates over a potential window from –0.2 to +0.8 V with MoS₂ as the working electrode, platinum as the counter electrode and Ag/AgCl as the reference electrode. The loaded mass of the synthesised MoS₂ on the working electrode was around 3–4 mg for each sample. Charge–discharge characterisations were performed at different specific currents within the potential window from –0.2 to +0.8 V with a similar experimental setup. Electrochemical impedance spectroscopy (EIS) measurements were carried out in the range from 100 MHz to 100 kHz with an AC amplitude of 10 mV in 1 M H₂SO₄ electrolyte.

Results and discussion

The XRD patterns of synthesised MoS₂ and nitrogen-doped MoS₂ nanostructures are depicted in Fig. 1(a–d) for 2θ range from 10° to 80°. The intense and broad reflection peaks confirm the formation of the 2H-MoS₂ nanostructure for all the prepared compositions. The XRD pattern of the synthesised MoS₂

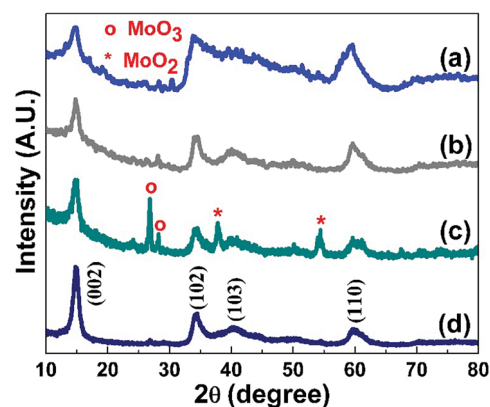


Fig. 1 X-ray diffraction patterns for MoS₂ (a), MoS₂-400 (b), MoS₂-N1 (c), and MoS₂-N5 (d).

matches the standard MoS₂ pattern (JCPDS ICDD no. 37-1492). The observed XRD peaks at $2\theta = 14.53^\circ$, 32.67° , 33.50° , 35.87° , 39.53° , 58.33° , and 60.14° correspond to (002), (100), (101), (102), (103), (110), and (008) *hkl* planes of hexagonal MoS₂. The XRD patterns of nitrogen-doped MoS₂ nanostructures (MoS₂-N1 and MoS₂-N5) are compared with the XRD patterns of as-synthesised MoS₂ and MoS₂-400, as depicted in Fig. 1(a–d). After nitrogen doping, there is slight change in the XRD peak intensity, but the peak positions remain the same. In the case of MoS₂-N1 sample, the formation of MoO₂ and MoO₃ along with MoS₂ is observed; this clearly indicates the formation of MoO₂/MoO₃/MoS₂ nanocomposites. The reflection peaks due to MoO₂ and MoO₃ match with JCPDS no. 32-0671 and 47-1081, respectively. Composite formation is observed for MoS₂-N1 sample only. Even though the synthesis methods for MoS₂-N1 and MoS₂-N5 are similar, the conversion of MoS₂ to MoO₂/MoO₃ is different, as seen in the XRD pattern. In the case of MoS₂-N1, the amount of carbon available (in the form of urea) to react with oxygen to form carbon dioxide is low as compared to that for MoS₂-N5. Therefore, for MoS₂-N1, the remaining oxygen reacts with MoS₂ to form molybdenum oxide. Thus, we observe difference in oxide formations for MoS₂-N1 and MoS₂-N5.

The broadening of the XRD peak decreases, indicating a more crystalline structure for nitrogen-doped MoS₂. The broad XRD peaks confirm that the prepared structures are still in the nanoscale even after heating at 400 °C for nitrogen doping. Furthermore, structural analysis of prepared MoS₂ and nitrogen-doped MoS₂ are conducted by Raman spectroscopy. Fig. 2(a–d) shows the Raman scattering curves for MoS₂, MoS₂-400, MoS₂-N1 and MoS₂-N5 in the range from 350 to 450 cm⁻¹. The two peaks correspond to in-plane (E_{2g}¹) and out-of-plane (A_{1g}¹) vibrations at 378 and 403 cm⁻¹ for the synthesised MoS₂ materials. These two characteristic Raman peaks confirm the formation of nanoscale MoS₂. There is negligible change in the peak separation between A_{1g} and E_{2g}¹ for nitrogen-doped MoS₂ compare to that for pristine MoS₂. The A_{1g}/E_{2g}¹ ratios for MoS₂, MoS₂ 400, MoS₂-N1 and MoS₂-N5 are 2.3, 2.7, 2.2 and 2.1,

respectively. The A_{1g}/E_{2g}¹ ratio decreases from MoS₂ 400 to MoS₂-N5, confirming that the defect edge sites of MoS₂ are occupied by nitrogen species.

The surface and morphological studies of prepared MoS₂ nanomaterials were carried out using FESEM and TEM analysis. The magnified images of MoS₂, MoS₂-400, MoS₂-N1, and MoS₂-N5 are shown in Fig. 3(a–d). The formation of flower-like nanostructures is observed in the prepared MoS₂ samples. The flower-like nanostructure is formed by stacking of nanosheets up to 20–50 nm thickness. As exhibited in Fig. 3(b), MoS₂-400 shows growth and an opening of nanosheets into flower-shaped nanostructures. The nitrogen doping in MoS₂ nanostructures results in rupturing of nanosheets in MoS₂-N1 and MoS₂-N5, as shown in Fig. 3(c and d). In the case of MoS₂-N1 sample, the existence of rods and rectangular plates is observed, which may be due to the formation of MoO₂ and MoO₃ nanostructures (ESI, Fig. S1†). Further detailed study related to oxide formation is confirmed by TEM analysis.

Microstructural analysis of prepared MoS₂ nanomaterials was conducted using TEM analysis, and the images are shown in Fig. 4. Fig. 4 shows the TEM images of MoS₂ (a and e), MoS₂-400 (b and f), MoS₂-N1 (c and g) and MoS₂-N5 (d and h). The layered structure of prepared MoS₂ is confirmed from TEM analysis. TEM clearly indicates the formation of flower-like morphology consisting of stacked nanosheets as flower petals, and this is consistent with the FESEM results. The size of petals in the as-synthesised MoS₂ is between 20 and 50 nm; for MoS₂-400, the size is between 20 and 80 nm. However, it is observed that the petal size range is decreased to 20–40 nm in the case of MoS₂-N1. Every petal is formed by stacking of two-dimensional MoS₂ nanosheets, as can be seen in Fig. 4(e–h). As discussed in the FESEM analysis, an opening of the nanosheets in MoS₂-400 can be seen in Fig. 4(f) as the interlayer distance increases from ~6.9 Å to ~7.5 Å compared with that observed for pristine MoS₂. As discussed in XRD and FESEM analysis, the formation of MoO₂/MoO₃/MoS₂ nanocomposites can be seen in Fig. 4(g) for the MoS₂-N1 nanomaterial. In the case of MoS₂-N5, such composite formation is not observed. The selected area electron

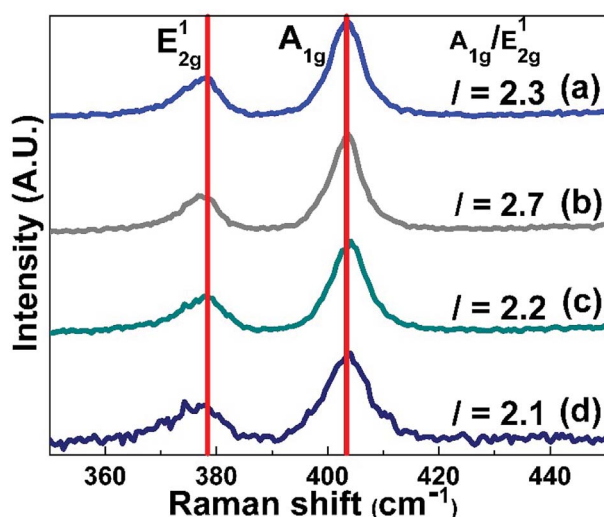


Fig. 2 Raman spectra for MoS₂ (a), MoS₂-400 (b), MoS₂-N1 (c), and MoS₂-N5 (d).

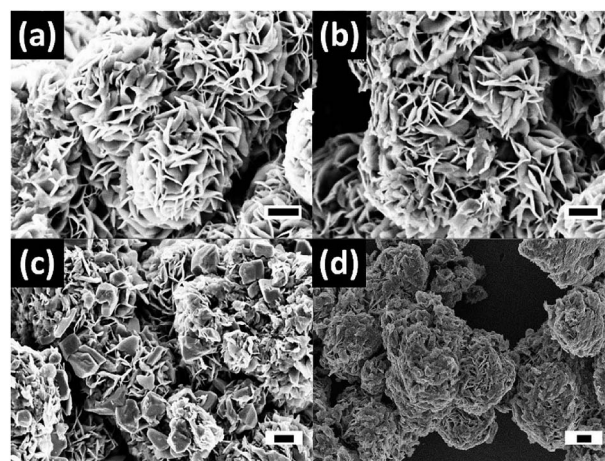


Fig. 3 FESEM images of low and high magnification for MoS₂ (a), MoS₂-400 (b), MoS₂-N1 (c), and MoS₂-N5 (d). Scale bars 400 nm (black).

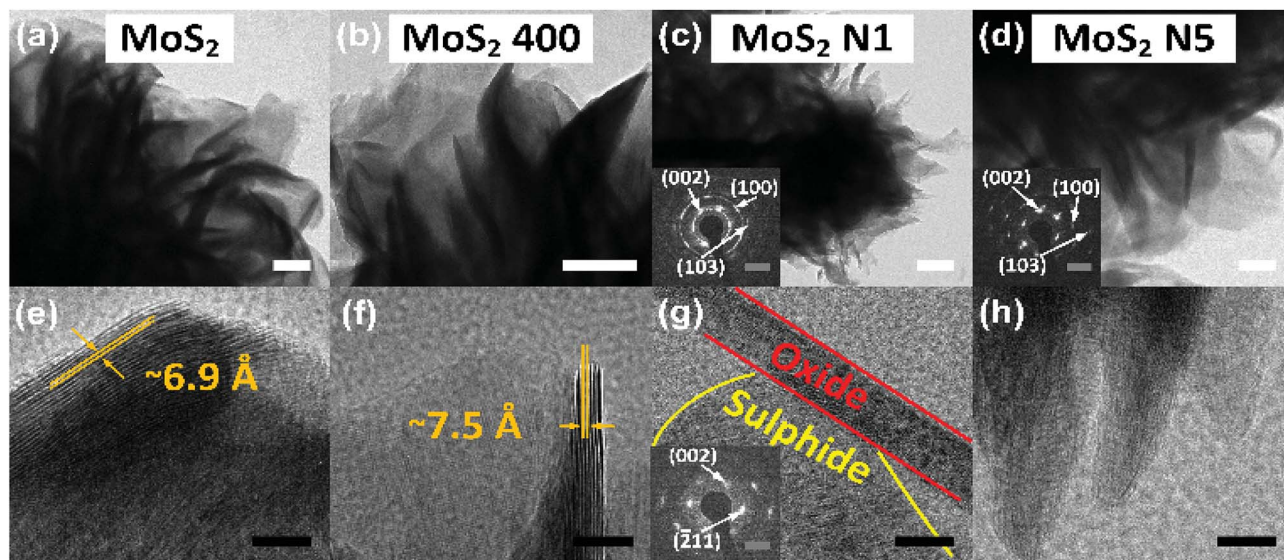


Fig. 4 TEM images for flower petals and stacked nanosheets for (a and b) MoS_2 , (c and d) MoS_2 -400, (e and f) MoS_2 -N1, and (g and h) MoS_2 -N5. Scale bars: 100 nm (white) and 5 nm (black). Insets show the SAED ring patterns for (e) MoS_2 -N1 flower petal, (f) MoS_2 -N1 rod/plates and (g) MoS_2 -N5 flower. Inset scale bars, 5 nm^{-1} (grey).

diffraction (SAED) pattern confirms that the rod- and plate-like structure shows the oxide phase, whereas the layered flowers exhibit the sulphide phase of nanomaterials. The insets in Fig. 4(c and g) show the SAED patterns for flowers and rods of MoS_2 -N1 nanomaterials, respectively, whereas the inset in Fig. 4(d) shows the SAED pattern for the flowers of MoS_2 -N5. The SAED pattern demonstrates intense patterns for different crystallographic planes. The hkl planes (002), (100), and (103) show the sulphide phase for the SAED patterns of MoS_2 -N1 and MoS_2 -N5 and are marked in the insets of Fig. 4(c and d). The (002) and (211) hkl planes of the oxide phase of MoS_2 -N1 are shown in Fig. 4(g). The hkl planes and their d spacing exactly match with those calculated from the XRD pattern. To confirm the formation of oxide/sulphide nanocomposites, elemental mapping is carried out, and the results are shown in the ESI (Fig. S2†). The elemental mapping clearly indicates the presence of oxide along with sulphides. Overall, the TEM analysis shows that the results are consistent with the XRD and FESEM results.

X-ray photoelectron spectroscopy (XPS) of the prepared MoS_2 samples was conducted to check the elemental composition of the materials. Fig. 5 shows the XPS spectra for MoS_2 (a), MoS_2 -400 (b), MoS_2 -N1 (c) and MoS_2 -N5 (d) for binding energies ranging from 394 eV to 408 eV. The N 1s peak around 399.1 eV confirms that nitrogen is present in MoS_2 -N1 and MoS_2 -N5 nanomaterials. Mo $3p_{3/2}$ can be observed at 395.5 eV in all synthesised materials. The XPS spectra for the Mo 3d peak and S 2p peak and survey scans of the prepared MoS_2 nanomaterials are provided in the ESI (Fig. S3†). The sulphur (S) to molybdenum (Mo) atomic percentage ratios for MoS_2 -N1 and MoS_2 -N5 are found to be 1.16 and 1.35, respectively. The deviation from the ideal stoichiometric ratio (S:Mo) indicates the amounts of oxygen and nitrogen present in MoS_2 -N1 and MoS_2 -N5 nanomaterials. The nitrogen-to-sulphur atomic percentage ratios are found to be 1.83 and 2.19 for MoS_2 -N1 and MoS_2 -N5, respectively. The ratio

confirms that the amount of nitrogen present in the MoS_2 -N5 nanomaterial is higher than that in MoS_2 -N1 nanostructures.

The electrochemical performances of prepared MoS_2 nanostructures are studied by cyclic voltammetry (CV) and galvanostatic charge-discharge (GCD) curves using a three-electrode system. The CV curves of the prepared MoS_2 nanomaterials were recorded in 1 M H_2SO_4 electrolyte for scan rates of 5, 20, 100, and 200 mV s^{-1} . The nearly rectangular and symmetric shape of the CV curves can be seen in Fig. 6(a) for as-synthesised MoS_2 . In Fig. 6(a), the oxidation and reduction peaks for Mo metal centre can be seen at lower step sizes (5 mV s^{-1} and 20 mV s^{-1}). These peaks lead to pseudocapacitance in the MoS_2 materials. The non-regular rectangular CV curve shows electrochemical double layer capacitance in the synthesised MoS_2 material. Fig. 6(b) shows a comparison of the CV curves at

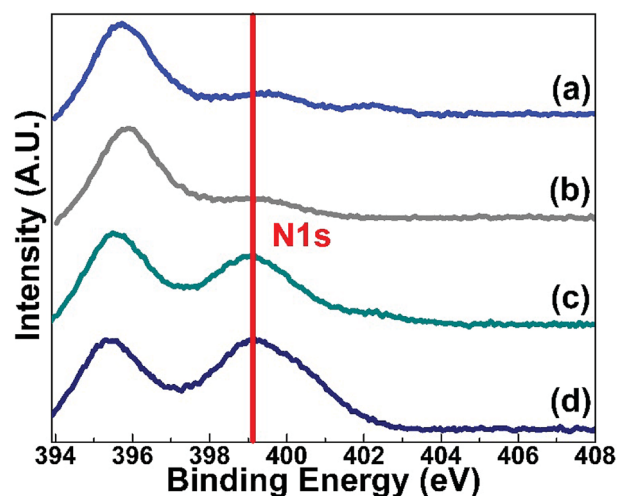


Fig. 5 XPS spectra for MoS_2 (a), MoS_2 -400 (b), MoS_2 -N1 (c) and MoS_2 -N5 (d) for binding energies ranging from 392 eV to 409 eV.

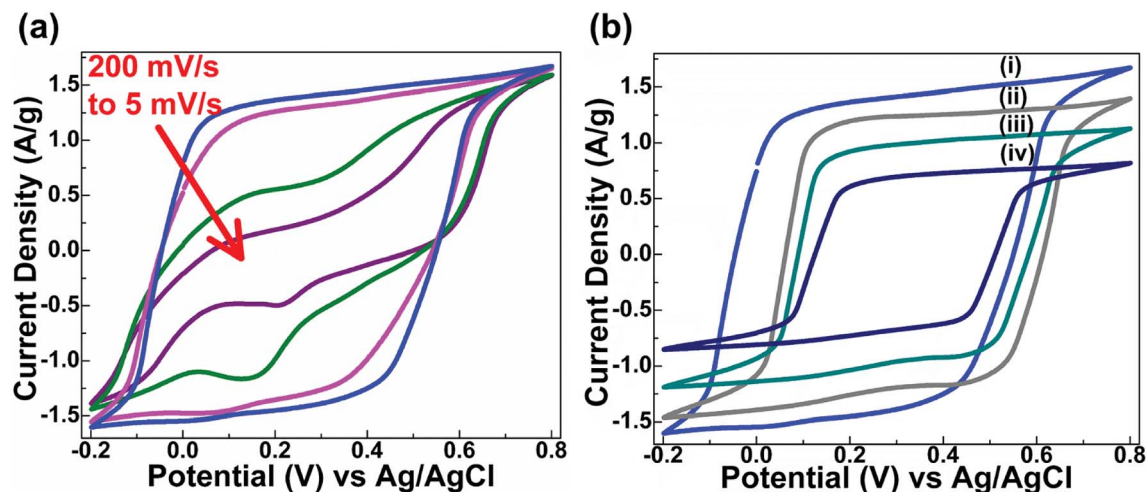


Fig. 6 (a) Cyclic voltammetry (CV) curves for as-synthesised MoS_2 nanomaterial for scan rates of 5 mV s^{-1} , 20 mV s^{-1} , 100 mV s^{-1} , and 200 mV s^{-1} (b) CV curves for (i) MoS_2 , (ii) MoS_2 -400, (iii) MoS_2 -N1, and (iv) MoS_2 -N5 at scan rate of 200 mV s^{-1} .

200 mV s^{-1} for MoS_2 , MoS_2 -400, MoS_2 -N1, and MoS_2 -N5. Furthermore, the capacitive performances of prepared MoS_2 nanostructures are evaluated by galvanostatic charge–discharge curves measured at different current densities (2, 3, 4, and 5 A g^{-1}) in $1 \text{ M H}_2\text{SO}_4$ electrolyte. The specific capacitance (C_s) values of the prepared MoS_2 nanomaterials are calculated from the GCD curves using the following equation:

$$C_s = (I \times \Delta t) / (m \times \Delta V)$$

Here, I is the discharge current (A), Δt is the discharge time (s), m is mass of active material (g), and ΔV is the potential window (V) for discharge time. The calculated values of specific capacitance are higher for lower current densities and subsequently decrease for higher current densities. This is a common observation in electrode materials due to charge resistive behaviour at higher current values. The specific capacitance values are higher for MoS_2 -N1 in comparison with those for other prepared MoS_2 materials from the GCD curves. The specific capacitance values for MoS_2 -N1 are 129, 99, 88, and 76 F g^{-1} in $1 \text{ M H}_2\text{SO}_4$ electrolyte at specific currents of 2, 3, 4, and 5 A g^{-1} , respectively. The specific capacitance values at 2 A g^{-1} for MoS_2 , MoS_2 -400, and MoS_2 -N5 are 34.9 , 35.6 , and 74.4 F g^{-1} , respectively. Fig. 7 shows the comparison between the calculated specific capacitance values at different specific currents for MoS_2 , MoS_2 -400, MoS_2 -N1, and MoS_2 -N5.

The electrochemical results show the enhanced specific capacitance for MoS_2 -N1 and MoS_2 -N5 as compared with that for MoS_2 . This confirms that nitrogen doping increases the capacitance of MoS_2 material. MoS_2 -N1 shows almost 3.5 times improvement in capacitance value relative to MoS_2 . MoS_2 -N1 has higher capacitance than MoS_2 -N5 due to the presence of N-doped $\text{MoO}_2/\text{MoO}_3/\text{MoS}_2$ composite material. The main reason behind the increase in specific capacitance can be correlated with the structure of the prepared nanomaterials, the composition and their electronic conductivities.

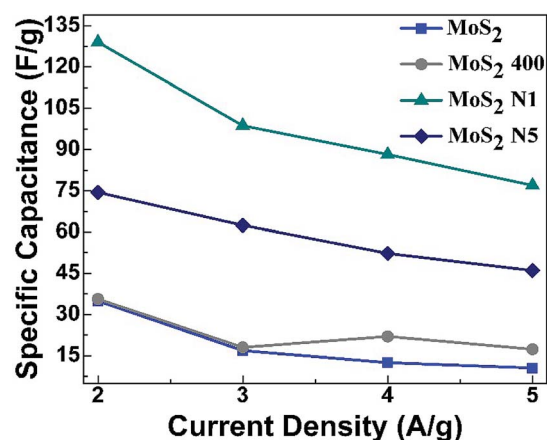


Fig. 7 The comparison between specific capacitances (F g^{-1}) of MoS_2 , MoS_2 -400, MoS_2 -N1, and MoS_2 -N5 vs. specific current (A g^{-1}).

Furthermore, electrochemical impedance spectroscopy (EIS) is performed to understand the charge kinetics and supercapacitor behaviour of prepared MoS_2 nanomaterials. Fig. 8(a) shows the Nyquist plots of MoS_2 , MoS_2 -400, MoS_2 -N1 and MoS_2 -N5. The prepared MoS_2 nanostructures show the supercapacitor feature, *i.e.*, a semicircle at higher frequencies and a straight line at the lower frequency region. The intercept on the real axis is ascribed to the equivalent series resistance (R_s), and the diameter of the semicircle corresponds to the charge transfer resistance (R_{ct}) in the electrode/electrolyte system. The R_s values for MoS_2 , MoS_2 -400, MoS_2 -N1 and MoS_2 -N5 are 2.16 , 2.63 , 1.89 and 1.16Ω , respectively. Nitrogen doping decreases the R_s values for MoS_2 -N1 and MoS_2 -N5. This confirms that nitrogen doping has enhanced the electrical conductivity of MoS_2 . The oxide/sulphide composite in MoS_2 -N1 may be responsible for the higher R_{ct} value (2.2Ω) in the Nyquist plot compared to that for other MoS_2 nanomaterials ($<1.5 \Omega$). The low frequency straight line parallel to the imaginary axis shows the capacitive behaviour of MoS_2 nanomaterials (Fig. 8(a)). The highest slope

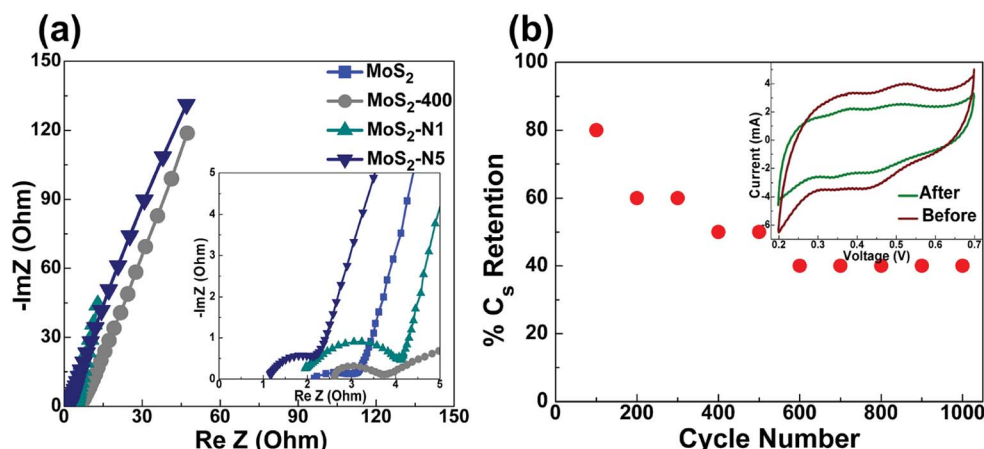


Fig. 8 (a) Nyquist Plots of MoS_2 , MoS_2 -400, MoS_2 -N1 and MoS_2 -N5; (inset shows the high frequency region of (a)). (b) % C_s retention vs. cycle number for MoS_2 -N1 electrode; (inset shows CV at 100 mV scan rate before and after 1000 cycles).

Table 1 The comparison of specific capacitance of reported MoS_2 only materials at specific current and electrolyte. (The contents in the table are arranged in decreasing order of specific current for comparison.)

Sr. no.	Method	Phase	Morphology	Specific capacitance (F g^{-1})	Reference
1	Hydrothermal	2-H	Flowers	129 at 2 A g^{-1} in $1 \text{ M H}_2\text{SO}_4$	This work
2	Two step hydrothermal	2-H	3D flower	168 at 1 A g^{-1} in 1 M KCl	34
3	DC magnetron sputtering	2-H	Nanoworms	138 F g^{-1} at 1 A g^{-1} in $1 \text{ M Na}_2\text{SO}_4$	35
4	Hydrothermal	2-H	Flower-like	129.2 F g^{-1} at 1 A g^{-1} in $1 \text{ M Na}_2\text{SO}_4$	36
5	CVD	2-H	Nanowall	100 F g^{-1} at 1 mV s^{-1} in $0.5 \text{ M H}_2\text{SO}_4$	37
6	Hydrothermal	2-H	Nanosphere	122 at 0.5 A g^{-1} in $1 \text{ M Na}_2\text{SO}_4$	18

of the straight line is obtained for MoS_2 -N1, suggesting that MoS_2 -N1 has optimal performance among the prepared MoS_2 nanostructures. The EIS measurements also support that nitrogen doping enhances the conductive performance of prepared MoS_2 nanostructures.

The cycling stability of MoS_2 -N1 material is studied by cyclic charge–discharge at 1 A g^{-1} current density in $1 \text{ M H}_2\text{SO}_4$ electrolyte. Fig. 8(b) shows the stability of the prepared MoS_2 -N1 electrode over 1000 cycles. The CV measurements at 100 mV s^{-1} scan rate are also recorded before and after 1000 cycles. The CV analysis shows almost 70% capacitance retention after 1000 cycles. The charge–discharge cycles show 40% retention in specific capacitance for MoS_2 -N1 after 1000 cycles.

The synthesised MoS_2 -N1 shows similar crystallographic phase and structure to that of reported MoS_2 nanostructures. The comparison of specific capacitances of prepared MoS_2 -N1 and reported MoS_2 nanostructures at a specific current and electrolyte is depicted in Table 1. In comparison with the reported MoS_2 nanostructures, the synthesised MoS_2 -N1 shows higher specific capacitance at a higher current density, *i.e.*, 129 F g^{-1} at 2 A g^{-1} in $1 \text{ M H}_2\text{SO}_4$. Fig. 7 confirms that the specific capacitance decreases as the specific current increases. Thus, higher specific capacitance at high current density shows the superiority of MoS_2 -N1 over other reported materials. Therefore, MoS_2 -N1 is a better electrode material because it exhibits higher specific capacitance at higher specific currents compared to reported 2H- MoS_2 materials.

Conclusion

The successful synthesis of nitrogen-doped MoS_2 hierarchical nanostructures was demonstrated by a simple low-cost synthesis method. The structural and morphological characterisation confirmed the formation of flower-like nanostructures of hexagonal MoS_2 along with the formation of oxide/sulphide nanocomposites. MoS_2 -N1 showed specific capacitance of 129 F g^{-1} at a specific current of 2 A g^{-1} . The formed nitrogen-doped $\text{MoO}_2/\text{MoO}_3/\text{MoS}_2$ nanocomposites showed four-fold enhancement in specific capacitance than the as-synthesised MoS_2 nanostructures. These results suggest that nitrogen-doped $\text{MoO}_2/\text{MoO}_3/\text{MoS}_2$ nanocomposites can be promising electrode materials for supercapacitor applications.

Conflicts of interest

There are no conflicts to declare.

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